09/803,034

09/803/039						
L Number	Hits		DB	Time stamp		
1	59519		USPAT;	2002/11/12 17:02		
ļ	ĺ	optoelectronic 428/690.ccls.	US-PGPUB;			
			EPO; JPO;			
2	5883	minus and /-3 3	DERWENT			
*	3003	pixel and (electroluminesc\$ or	USPAT;	2002/11/12 16:41		
		opto-electronic or optoelectronic 428/690.ccls.)	US-PGPUB;			
		420/090.CCIS.)	EPO; JPO;			
3	2509	(pixel and (electroluminesc\$ or	DERWENT	1		
	2309	opto-electronic or optoelectronic	USPAT;	2002/11/12 16:53		
		428/690.ccls.)) and (insulat\$ or barrier or	US-PGPUB;			
		silicon) and (projection or slope or step)	EPO; JPO;			
4	15	((cathode and anode) same (projection or	DERWENT	0000/11/12 12		
		slope)) and ((pixel and (electroluminesc\$ or	USPAT;	2002/11/12 16:47		
		opto-electronic or optoelectronic	US-PGPUB;	1		
		428/690.ccls.)) and (insulat\$ or barrier or	EPO; JPO; DERWENT			
		silicon) and (projection or slope or step))	DERWENT			
5	46	(pixel same slope) and ((pixel and	HODAW.	2002/11/10 15 15		
		(electroluminesc\$ or opto-electronic or	USPAT;	2002/11/12 16:47		
		optoelectronic 428/690.ccls.)) and	US-PGPUB; EPO; JPO;			
		(insulat\$ or barrier or silicon) and	DERWENT			
		(projection or slope or step))	DERWENT			
6	98	"step coverage" and ((pixel and	USPAT;	2002/11/12 16:47		
		(electroluminesc\$ or opto-electronic or	US-PGPUB;	2002/11/12 16:4/		
1		optoelectronic 428/690.ccls.)) and	EPO; JPO;			
		(insulat\$ or barrier or silicon) and	DERWENT			
		(projection or slope or step))				
7	138	(((pixel same slope) and ((pixel and	USPAT;	2002/11/12 16:48		
		(electroluminesc\$ or opto-electronic or	US-PGPUB;	,,		
		optoelectronic 428/690.ccls.)) and	EPO; JPO;			
1		(insulat\$ or barrier or silicon) and	DERWENT			
		(projection or slope or step))) or ("step		*		
		coverage" and ((pixel and (electroluminesc\$				
		or opto-electronic or optoelectronic				
		428/690.ccls.)) and (insulat\$ or barrier or				
		silicon) and (projection or slope or				
		step)))) not (((cathode and anode) same				
	•	(projection or slope)) and ((pixel and				
		(electroluminesc\$ or opto-electronic or		•		
		optoelectronic 428/690.ccls.)) and	ĺ			
		(insulat\$ or barrier or silicon) and		•		
8	135	<pre>(projection or slope or step))) (silicon or insulating or insulation or</pre>				
	133	insulate) and (((pixel same slope) and	USPAT;	2002/11/12 16:49		
		((pixel and (electroluminesc\$ or	US-PGPUB;			
		opto-electronic or optoelectronic	EPO; JPO;			
		428/690.ccls.)) and (insulat\$ or barrier or	DERWENT			
		silicon) and (projection or slope or step)))				
		or ("step coverage" and ((pixel and		-		
		(electroluminesc\$ or opto-electronic or				
[optoelectronic 428/690.ccls.)) and				
		(insulat\$ or barrier or silicon) and				
		(projection or slope or step)))) not				
		(((cathode and anode) same (projection or				
		slope)) and ((pixel and (electrolumineses or				
		opto-electronic or optoelectronic	1			
		428/690.ccls.)) and (insulats or barrier or				
	1	silicon) and (projection or slope or				
		step))))	ļ			

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9	40	(0-0) + (0015: Of 420) 517.CCIS. Of	USPAT;	2002/11/12 17:02
	Ì	428/690.ccls.) and ((silicon or insulating	US-PGPUB;	
		or insulation or insulate) and (((pixel	EPO; JPO;	1
	İ	same slope) and ((pixel and	DERWENT	
	i	(electroluminesc\$ or opto-electronic or		1
		optoelectronic 428/690.ccls.)) and		
	1	(insulat\$ or barrier or silicon) and		ĺ
		(projection or slope or step))) or ("step	İ	
	i	coverage" and ((pixel and (electroluminesc\$	1	
		or opto-electronic or optoelectronic	İ	
		428/690.ccls.)) and (insulats or barrier or		
		silicon) and (projection or slope or		
	į	step)))) not (((cathode and anode) same		
		(projection or slope)) and ((pixel and		
	1	(electrolyminossis or onto electrolyminossis or onto		1
		(electroluminesc\$ or opto-electronic or		
		optoelectronic 428/690.ccls.)) and		1
		(insulat\$ or barrier or silicon) and		
10		(projection or slope or step)))))	1	
		(313/\$.ccls. or 428/917.ccls. or	USPAT;	2002/11/12 16:58
		428/690.ccls.) and (insulat\$ with slope) and	US-PGPUB;	
		((pixel and (electroluminesc\$ or	EPO; JPO;	
		opto-electronic or optoelectronic	DERWENT	
		428/690.ccls.)) and (insulats or barrier or		1
11	1	silicon) and (projection or slope or step))		
	3	1 = = 7 7 . 00=0. 02 120/ 01/.0018. 01	USPAT;	2002/11/12 17:01
	İ	428/690.ccls.) and (insulat\$ with slope) and	US-PGPUB;	, ==, == = : : : :
	}	((pixel and (electroluminesc\$ or	EPO; JPO;	
		opto-electronic or optoelectronic	DERWENT	
	1	428/690.ccls.)) and (insulats or barrier or	,	•
		(Silicon) and (projection or slope or step)))		
		not ((313/\$.ccls. or 428/917.ccls. or		
	ļ	428/690.ccls.) and ((silicon or insulating		1
	,	or insulation or insulate) and (((nivel		
	1	same slope) and ((pixel and		
	ļ	(electroluminesc\$ or opto-electronic or		l i
	İ	optoelectronic 428/690.ccls.)) and	1	i
		(insulat\$ or barrier or silicon) and		
		(projection or slope or step))) or ("step		
	ĺ	coverage" and ((pixel and (electroluminesc\$		[
	1	or opto-electronic or optoelectronic		,
		428/690.ccls.)) and (insulat\$ or barrier or		
		silicon) and (projection or slope or		
		step)))) not (((cathode and anode) same		J
	ĺ	(projection or slope)) and ((pixel and		
		(electroluminesc\$ or opto-electronic or		1
		optoelectronic 428/690.ccls.)) and]
		(insulat\$ or barrier or silicon) and		
	-	(projection or close or strict)		l.
13	53	<pre>(projection or slope or step)))))) ichio.in. and yudasaka.in.</pre>		
	, ,,	Tenio.in. and yudasaka.in.	USPAT;	2002/11/12 17:02
			US-PGPUB;	
		·	EPO; JPO;	
	ا ۾ ا		DERWENT	
	8	(ichio.in. and yudasaka.in.) and	USPAT;	2002/11/12 17:02
		(electroluminesc\$ or opto-electronic or	US-PGPUB;	,, 1, .02
		optoelectronic 428/690.ccls.)	EPO; JPO;	
			DERWENT	